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CONFIRMATION NO. 7189

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10/519,837		438	2822	264197US0PCT

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## \*\* CONTINUING DATA \*\*\*\*\*

This application is a 371 of PCT/JP03/08333 06/30/2003

## \*\* FOREIGN APPLICATIONS \*\*\*\*\*

*TM* JAPAN 2002-208515 07/17/2002

## \*\* IF REQUIRED, FOREIGN FILING LICENSE GRANTED \*\*

Foreign Priority claimed	<input checked="" type="checkbox"/> Yes <input type="checkbox"/> No	<input type="checkbox"/> Met after Allowance	STATE OR COUNTRY	SHEETS DRAWINGS	TOTAL CLAIMS	INDEPENDENT CLAIMS
35 USC 119(a-d) conditions met	<input checked="" type="checkbox"/> Yes <input type="checkbox"/> No	<i>TM</i> Initials	JAPAN	8	17	4

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## TITLE

High-resistance silicon wafer and process for producing the same

FILING FEE RECEIVED 1230	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:	<input type="checkbox"/> All Fees
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